

**IN THE CLAIMS:**

Please amend claims 11, 15 and 16 and add new claims 17-19 as follows:

**LISTING OF CURRENT CLAIMS**

Claim 1. (Original) A light-emitting semiconductor device having enhanced brightness, comprising:

- (a) a semiconductor substrate;
- 5 (b) an active layer located above the semiconductor substrate, for inducing illumination of light;
- (c) a conductive back contact located below the semiconductor substrate; and
- 10 (d) a conductive front contact located above the active layer, the front contact including a metallic bonding pad and ohmic contact having a minimum dimension ranging between 0.1 and 5 micrometers and distributed above the active layer.

Claim 2. (Original) The light-emitting semiconductor device having enhanced brightness of Claim 1, wherein the semiconductor substrate is GaAs.

Claim 3. (Original) The light-emitting semiconductor device having enhanced brightness of Claim 2, wherein the active layer is AlGaInP.

Claim 4. (Original) The light-emitting semiconductor device having enhanced brightness of Claim 2, wherein the active layer is AlGaAs.

Claim 5. (Original) The light-emitting semiconductor device having enhanced brightness of Claim 1, wherein the semiconductor substrate is sapphire.

Claim 6. (Original) The light-emitting semiconductor device having enhanced brightness of Claim 4, wherein the active layer is AlGaInN.

Claim 7. (Original) The light-emitting semiconductor device having enhanced brightness of Claim 1, wherein the active layer and the front contact is provided with a capping layer therebetween.

Claim 8. (Original) The light-emitting semiconductor device having enhanced brightness of Claim 1, wherein the metallic patterns of the front contact is configured to an interconnected mesh and in electrical connection with the metallic bonding pad.

Claim 9. (Original) The light-emitting semiconductor device having enhanced brightness of Claim 1, wherein the metallic patterns of the front contact are disconnected.

Claim 10. (Original) The light-emitting semiconductor device having enhanced brightness of Claim 1, wherein the metallic patterns of the front contact are disconnected, and in electrical connection with the metallic bonding pad by means of a conductive layer incapable of absorbing light illuminated by the active layer.

Claim 11. (Currently Amended) The light-emitting semiconductor device having enhanced brightness of Claim 7 ~~or~~ 8, wherein the metallic patterns of the front contact are embedded and interconnected in an ITO layer.

Claim 12. (Original) A light-emitting device having enhanced brightness, comprising:

- (a) a substrate;
- (b) an active layer located above the substrate, for inducing illumination of light;
- (c) a back contact located below the substrate; and
- (d) a front contact located above the active layer, the front contact including a metallic bonding pad and ohmic contact metallic patterns, the metallic patterns of the front contact having a minimum dimension ranging between 0.1 and 5 micrometers and distributed above the active layer.

Claim 13. (Original) The light-emitting semiconductor device having enhanced brightness of Claim 12, wherein the metallic patterns of the front contact is configured to an interconnected mesh and in electrical connection with the metallic bonding pad.

Claim 14. (Original) The light-emitting semiconductor device having enhanced brightness of Claim 12, wherein the metallic patterns of the front contact are disconnected.

Claim 15. (Currently Amended) The light-emitting semiconductor device having enhanced brightness of Claim 13 or 14, wherein the metallic patterns are in electrical connection with the metallic bonding pad by means of a conductive layer incapable of absorbing light illuminated by the active layer.

Claim 16. (Currently Amended) The light-emitting semiconductor device having enhanced brightness of Claim 13 or 14, wherein the metallic patterns of the front contact are embedded and interconnected in an ITO layer.

Claim 17. (New) The light-emitting semiconductor device having enhanced brightness of Claim 8, wherein the metallic patterns of the front contact are embedded and interconnected in an ITO layer.

Claim 18. (New) The light-emitting semiconductor device having enhanced brightness of Claim 14, wherein the metallic patterns are in electrical connection with the metallic bonding pad by means of a conductive layer incapable of absorbing light illuminated by the active layer.

Claim 19. (New) The light-emitting semiconductor device having enhanced brightness of Claim 14, wherein the metallic patterns of the front contact are embedded and interconnected in an ITO layer.